

Supporting Information for

**Multi-element co-penetration engineering in high-entropy alloys for efficient electromagnetic-wave absorption**

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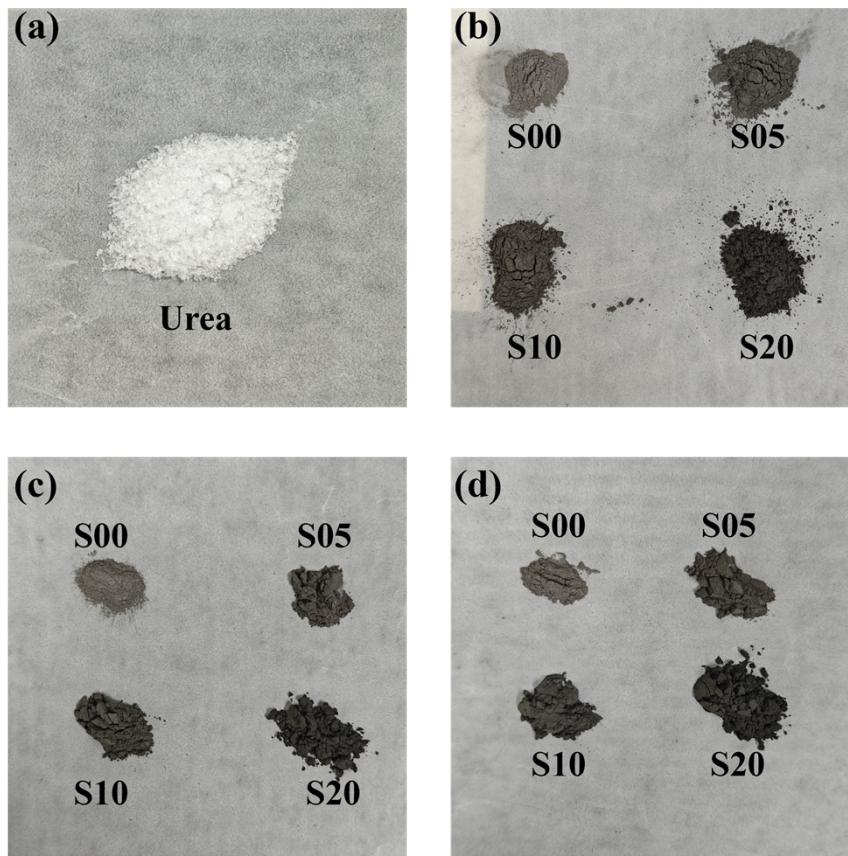
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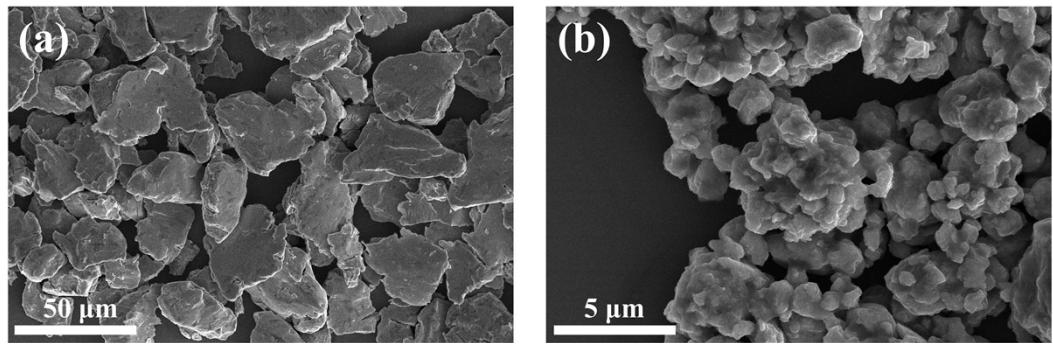
The corrosion resistance test in Fig. 4 (a-c) are as follows:

(1) An electrochemical workstation (CHI760E) is used to test the potentiodynamic polarization curve and electrochemical impedance spectra (EIS) in the 3.5 wt.% NaCl solution. The electrochemical tests adopt a three-electrode system. A sample-loaded carbon paper is used for the working electrode, and a platinum metal sheet and saturated calomel electrode (SCE) are used as auxiliary and reference electrodes, respectively. The open-circuit potential of samples is obtained after being soaked for 1800 s. The potentiodynamic polarization curves are measured at a scanning rate of 0.5 mV/s. Corrosion potential and corrosion current density are obtained from polarization curves. The EIS test is carried out with a scan amplitude of 5 mV and a frequency range of 100 kHz - 0.1 Hz.

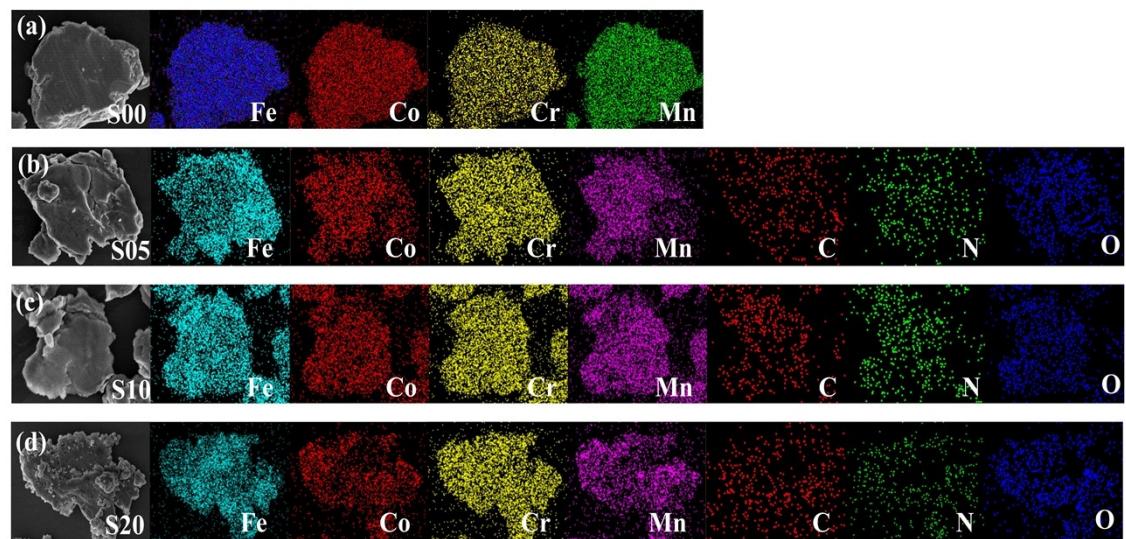
(2) The samples were prepared as follows: first, 5 mg of sample powder, 120  $\mu$ L of naphthol, 200  $\mu$ L of isopropanol and 600  $\mu$ L of deionized water were uniformly mixed. Subsequently, 35  $\mu$ L of the mixed solution was added dropwise onto a carbon paper with size of  $0.5 \times 0.5$  cm<sup>2</sup>. Finally, these samples were dried at 60 °C for 10 minutes.



**Fig. S1.** The photographs of (a) urea and (b-d) the prepared samples (S00, S05, S10 and S20).



**Fig. S2.** Comparison of surface morphology between (a) S00 and (b) S20.



**Fig. S3.** EDS element mapping images of (a) S00, (b) S05, (c) S10 and (d) S20.

**Table S1.** Melting point, crystal structure, atomic radius and Pauling electronegativity of raw materials.

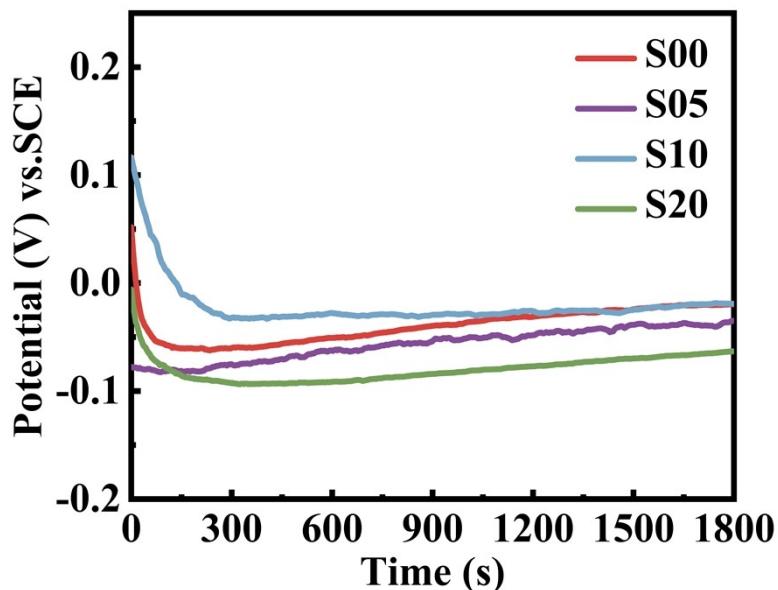
Element	Fe	Co	Cr	Mn	CH <sub>4</sub> N <sub>2</sub> O
<b>Melting point (°C)</b>	1538	1495	1907	1246	131~135
<b>Crystal structure</b>	BCC	HCP	BCC	BCC	-
<b>Atomic radius (pm)</b>	126	125	128	127	-
<b>Pauling electronegativity</b>	1.83	1.88	1.66	1.55	-

**Table S2.** Electrochemical parameters of equivalent circuit under different stray current density.

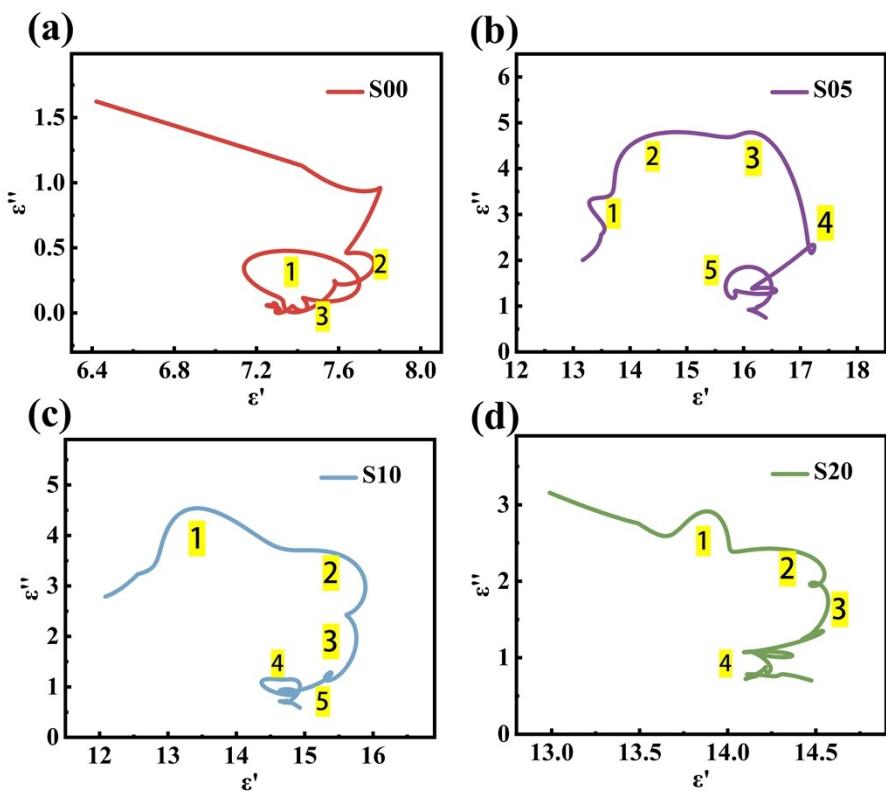
Samples	R <sub>s</sub>	Q-Yo	Q-n	R <sub>ct1</sub>	CPE	R <sub>ct2</sub>
<b>S00</b>	2.573	0.00039495	0.75483	62.08	0.00031653	8097
<b>S05</b>	5.2*10 <sup>-6</sup>	0.0018084	0.45683	67.6	0.00029686	1.4*10 <sup>5</sup>
<b>S10</b>	3.908	0.0005724	0.7369	80.48	0.00042727	54605
<b>S20</b>	3.135	0.00045736	0.74153	116	0.00048825	7.4*10 <sup>17</sup>

**Table S3.** Comparison of corrosion-resistance performances of different HEAs.<sup>1-6</sup>

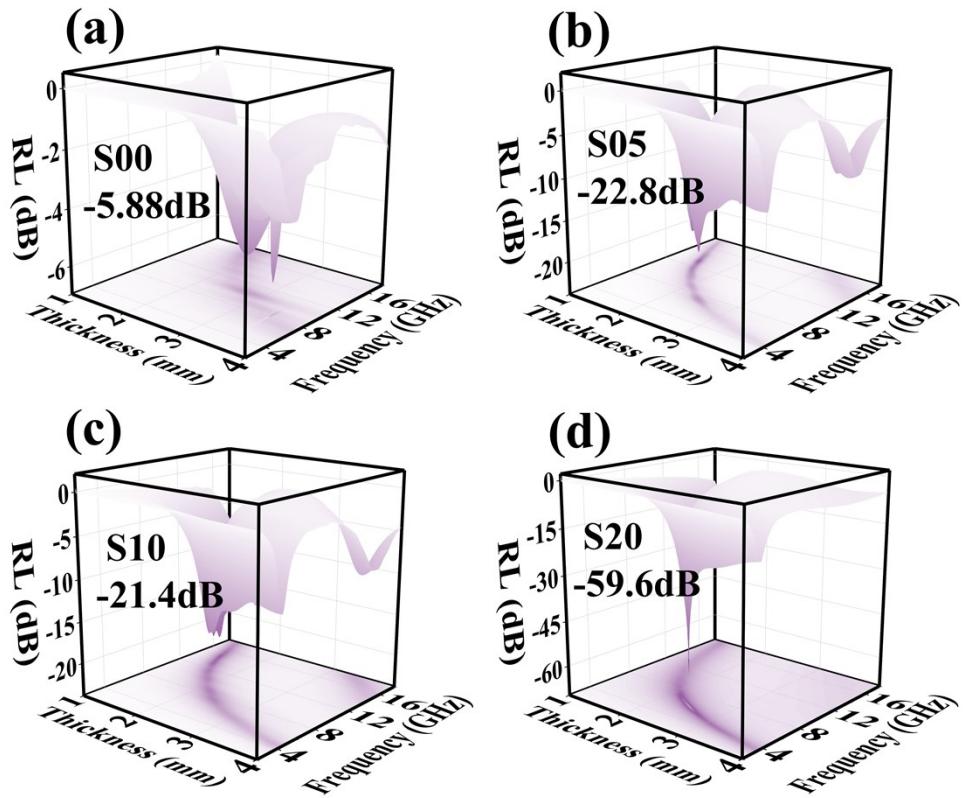
Samples	Solution	$I_{corr}$ ( $\mu\text{A}/\text{cm}^2$ )	$E_{corr}$ (mV)	Ref.
FeCoNiCu	3.5 wt.% NaCl	5.78	-0.43	Ref. 1
FeCoNiCuAlCe <sub>0.01</sub>	3.5 wt.% NaCl	5.27	-0.43	Ref. 1
FeCoNiCuAlCe <sub>0.03</sub>	3.5 wt.% NaCl	4.61	-0.43	Ref. 1
FeCoNiCuAlCe <sub>0.09</sub>	3.5 wt.% NaCl	4.01	-0.45	Ref. 1
FeCoNiAl <sub>0.3</sub>	3.5 wt.% NaCl	5.02	-0.204	Ref. 2
FeCoNiCrBSiNb	3.5 wt.% NaCl	5.20	-0.390	Ref. 3
Ti <sub>21.6</sub> Al <sub>11.3</sub> Cr <sub>19.4</sub> Si <sub>23.5</sub> V <sub>22.0</sub> O <sub>2.2</sub>	3.5 wt.% NaCl	6.14	-0.541	Ref. 4
FeCoNiCr	3.5 wt.% NaCl	2.51	-0.036	Ref. 5
FeCoNiMn	3.5 wt.% NaCl	4.90	-163	Ref. 6
S05	3.5 wt.% NaCl	2.62	-45.33	This work



**Fig. S4.** Open-circuit potentials of C/N/O co-interstitial penetration FeCoCrMn HEAs.



**Fig. S5.** The Cole–Cole semicircle patterns of (a) S00, (b) S05, (c) S10 and (d) S20.



**Fig. S6.** The 3D RL plots as a function of frequency at various thicknesses of (a) S00, (b) S05, (c) S10 and (d) S20.

**Table S4.** The comparison of RL performances of all samples in this work.

Samples	RL <sub>min</sub> (dB)	Frequency (GHz)	Thickness (mm)
<b>S00</b>	-5.9	/	/
<b>S05</b>	-22.8	13.12	1.46
<b>S10</b>	-21.4	14.54	1.37
<b>S20</b>	-59.6	6.06	2.48

**Table S5.** The comparison of comprehensive properties with related materials.<sup>1, 5, 7-12</sup>

Samples	RL (dB)	F (GHz)	EAB (GHz)	Thick ness (mm)	I <sub>corr</sub> (μA/cm <sup>2</sup> )	Ref.
<b>S20</b>	-59.6	6.06	6.86	1.32	3.17	This work
<b>FeCoNiCuS<sub>0.2</sub></b>	-55.4	6.52	7	2.16	3.59	Ref.7
<b>FeCoNiCuC<sub>0.04</sub></b>	-61.1	15.28	5.1	1.6	5.14	Ref.8
<b>FeCoNiCuC<sub>0.10</sub></b>	-59.9	6.78	5.2	2.8	9.25	Ref.8
<b>FeCoNiCuC<sub>0.1</sub>N<sub>0.2</sub></b>	-32.3	7.89	4.46	2.5	2.43	Ref.9
<b>FeCoNiCrB<sub>0.01</sub></b>	-64.5	12.43	5.08	2.66	8.729	Ref.5
<b>HCN<sub>S</sub></b>	-45.7	/	3.9	3.6	/	Ref.10
<b>FeCoNiMn<sub>0.5</sub>Al<sub>0.2</sub></b>	-44.4	/	3.825	3	/	Ref.11
<b>FeCoNiCuAlCe<sub>0.09</sub></b>	/	/	/	/	4.01	Ref.1
<b>FeCoNiCuC<sub>0.09</sub>N<sub>0.18</sub></b>	-55.8	15.82	3.82	2.38	0.51	Ref.12

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